

Special Issue

Chemical Engineering and Technology

Message from the Guest Editors

This Special Issue on *Chemical Engineering and Technology* intends to present novel examples of process design and optimization for all chemical processes. Topics include but are not limited to:

- Unit operations (hydrodynamic, heat and mass transfer processes);
- Fluid dynamics;
- Equipment and plant design (pressure vessels, tanks, steel structures);
- Safety processes and hazard development;
- Process system engineering.

Guest Editors

Dr. Máté Petrik

Dr. Gábor L. Szepesi

Dr. Zoltán Szamosi

Deadline for manuscript submissions

closed (31 March 2023)



Processes

an Open Access Journal
by MDPI

Impact Factor 2.8
CiteScore 5.1



mdpi.com/si/100758

Processes

MDPI, Grosspeteranlage 5
4052 Basel, Switzerland
Tel: +41 61 683 77 34
processes@mdpi.com

[mdpi.com/journal/
processes](https://mdpi.com/journal/processes)





Processes

an Open Access Journal
by MDPI

Impact Factor 2.8
CiteScore 5.1



[mdpi.com/journal/
processes](https://mdpi.com/journal/processes)



About the Journal

Message from the Editor-in-Chief

You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

Prof. Dr. Giancarlo Cravotto

Department of Drug Science and Technology, University of Turin, Via P. Giuria 9, 10125 Turin, Italy

Author Benefits

Open Access:

free for readers, with article processing charges (APC) paid by authors or their institutions.

High Visibility:

indexed within Scopus, SCIE (Web of Science), Ei Compendex, Inspec, AGRIS, and other databases.

Journal Rank:

JCR - Q2 (Engineering, Chemical) / CiteScore - Q2 (Chemical Engineering (miscellaneous))